

IP083: Transient Electric Field Effect-Based Characterization of an Ultrafast Electron Gun Suitable for Electron Diffraction and Microscopy



Leon Brauns¹, Johannes Otto^{1,2}, Armin Feist¹, Jan Gerrit Horstmann¹, Murat Sivis¹ and Claus Ropers^{1,2}

¹Max Planck Institute for Multidisciplinary Sciences, Am Fassberg 11, 37077 Göttingen

²Max Planck School of Photonics

Email: leon.brauns@stud.uni-goettingen.de

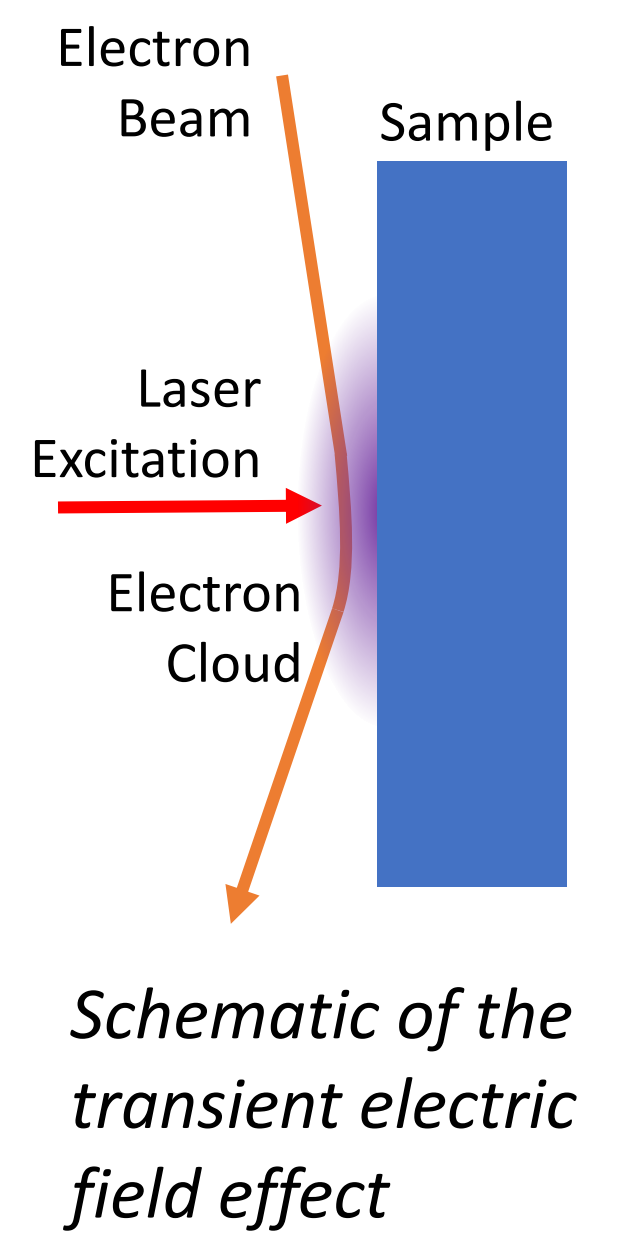
MAX PLANCK INSTITUTE
FOR MULTIDISCIPLINARY SCIENCES

Motivation

- Following the growing interest in the investigation of novel 2D materials, electron diffraction in the medium energy range up to 15kV is becoming more attractive [1]
- For the study of transient structural dynamics in such materials, ultrafast electron diffraction (UED) presents itself as a very promising technique
- The electron source characteristics thereby play a crucial role in the achievable spatial and temporal resolution
- Here we present an accessible and efficient approach to characterize the electron pulse duration of a 15kV ultrafast electron gun using the transient electric field effect
- We subsequently compare it with UED measurements of tantalum disulfide

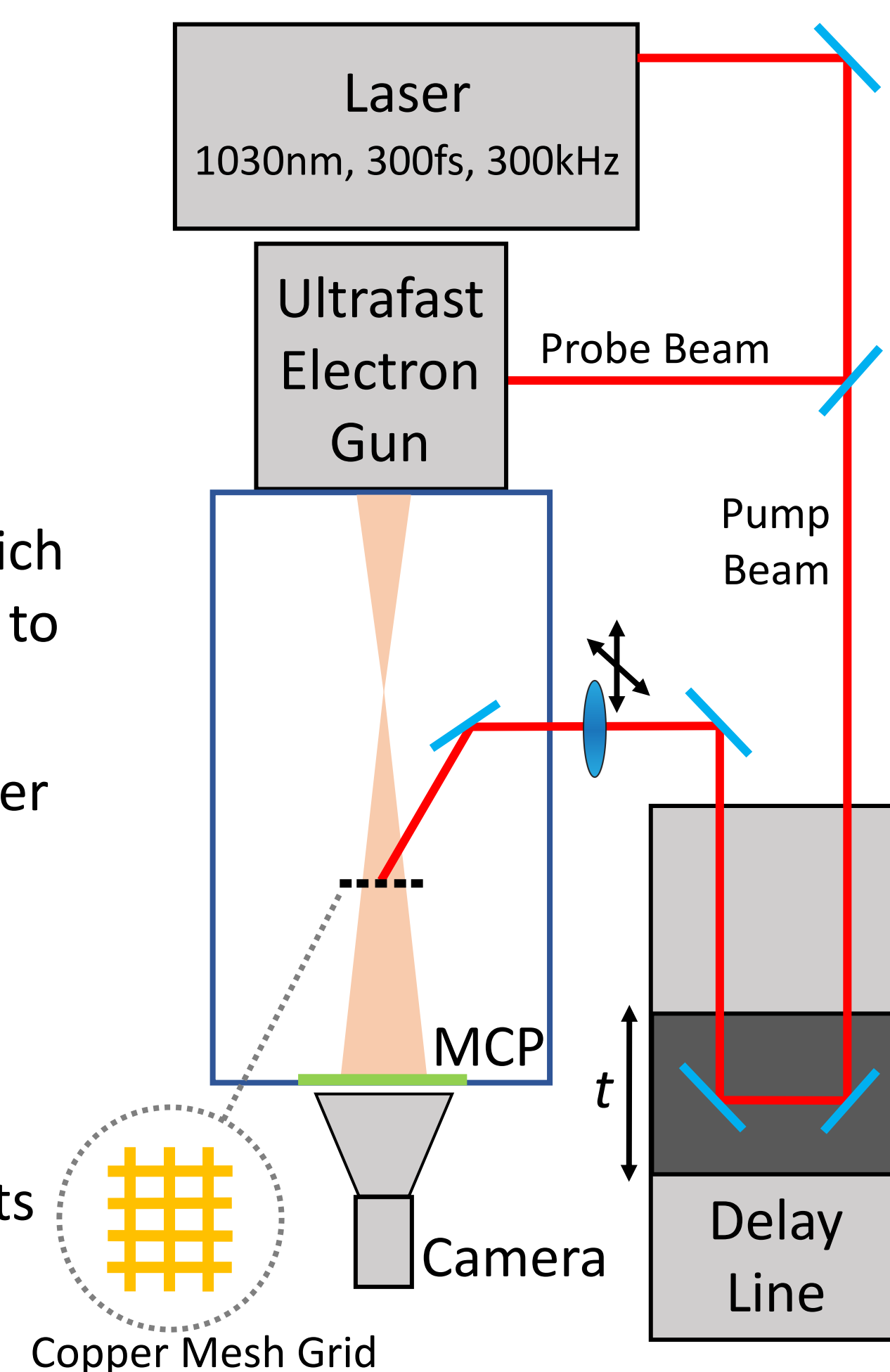
Transient Electric Field Effect

- Through ultrafast laser excitation of a surface, electrons are emitted similarly to thermal emission, as well as through multiphoton photoemission and thermally assisted multiphoton photoemission [2]
- The emerging electron cloud has a rise time in the order of a picosecond [3]
- The emitted electrons induce a transient electric field, capable of deflecting an incoming electron beam

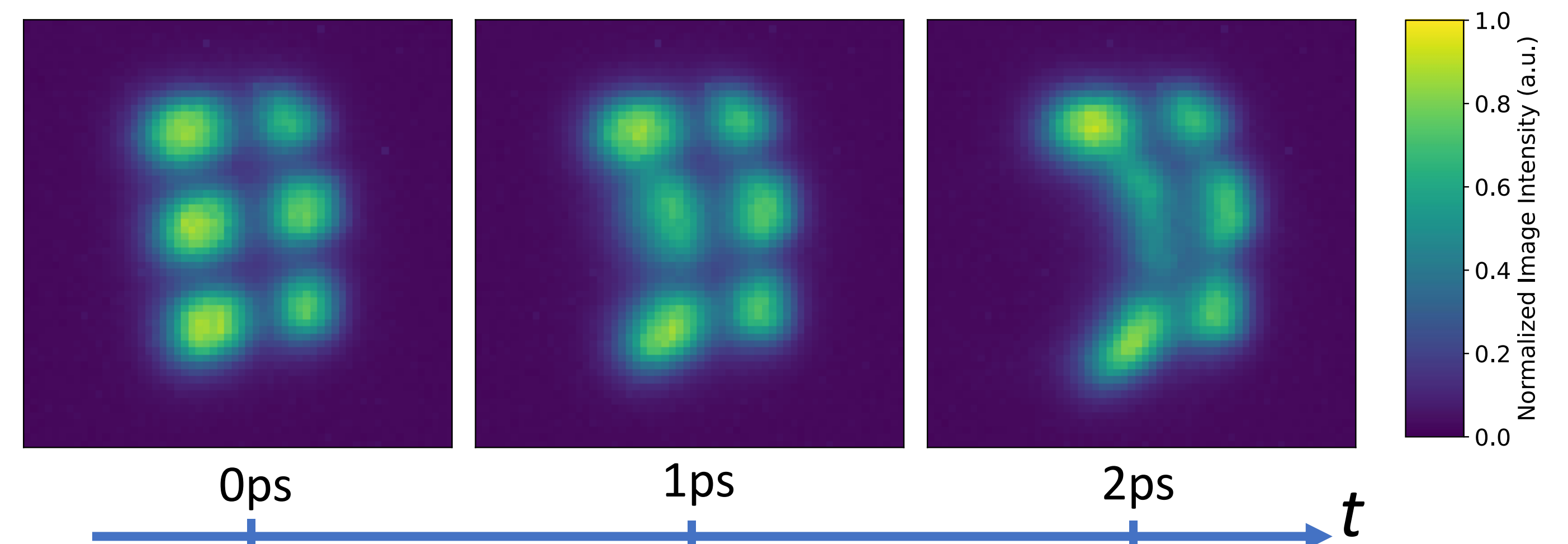


Experimental Setup

- The output of an ultrafast laser is split into a probe and pump beam path
- The probe pulse is fed into a laser-triggered ultrafast electron gun
- The pump pulse transverses a delay line, which allows the adjustment of the delay t relative to the probe pulse
- The pump pulse is then focused onto a copper mesh grid with a fluence of up to $20\text{mJ}/\text{cm}^2$
- Spatial overlap can be tuned by shifting the focusing lens
- The electron beam emitted from the gun is focused in front of the mesh grid and projects it onto a microchannel plate (MCP)

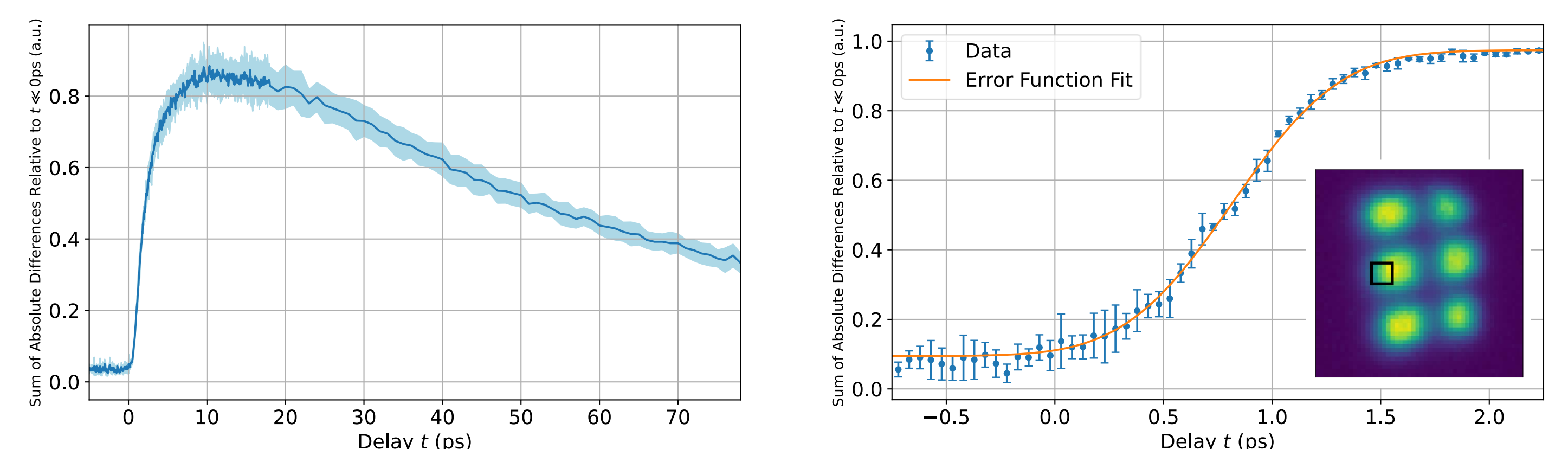


Measurement and Analysis



MCP images of the projected mesh grid for different delays t between laser pump and electron probe beam

- Deflection by the transient electric field is visible for $t > 0\text{ps}$
- Spatial overlap is easily distinguished and achieved by raster scanning the pump focus spot over the sample surface
- Snapshots of the imaged mesh grid are captured for different delays t for an analysis of the dynamics

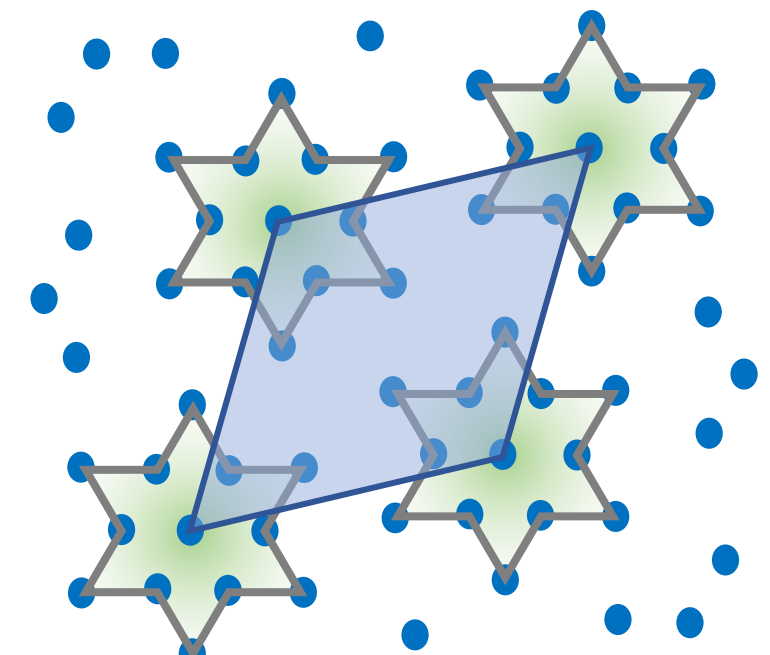


MCP Image intensity change relative to $t \ll 0$ for different delays t for the whole mesh grid projection (left) and within a selected area (right)

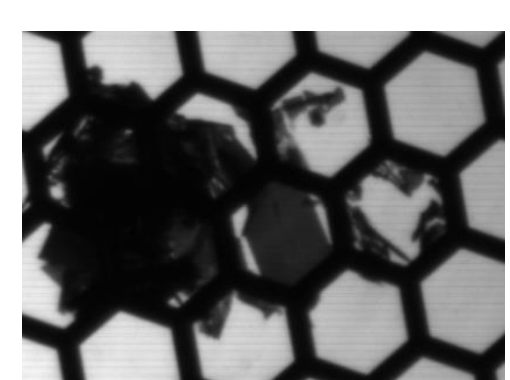
- The expanding electron cloud is clearly observable with a rise time within 10ps and a slow decay duration of more than 100ps
- To characterize the electron pulse duration, the intensity change enclosed in a small area within the mesh cell closest to the origin of the emerging electron cloud is analyzed
- An error function is fitted to the data, from which the full width at half maximum (FWHM) of the electron pulse length is determined to be $1.31(3)\text{ps}$

Ultrafast Electron Diffraction of 1T-TaS₂

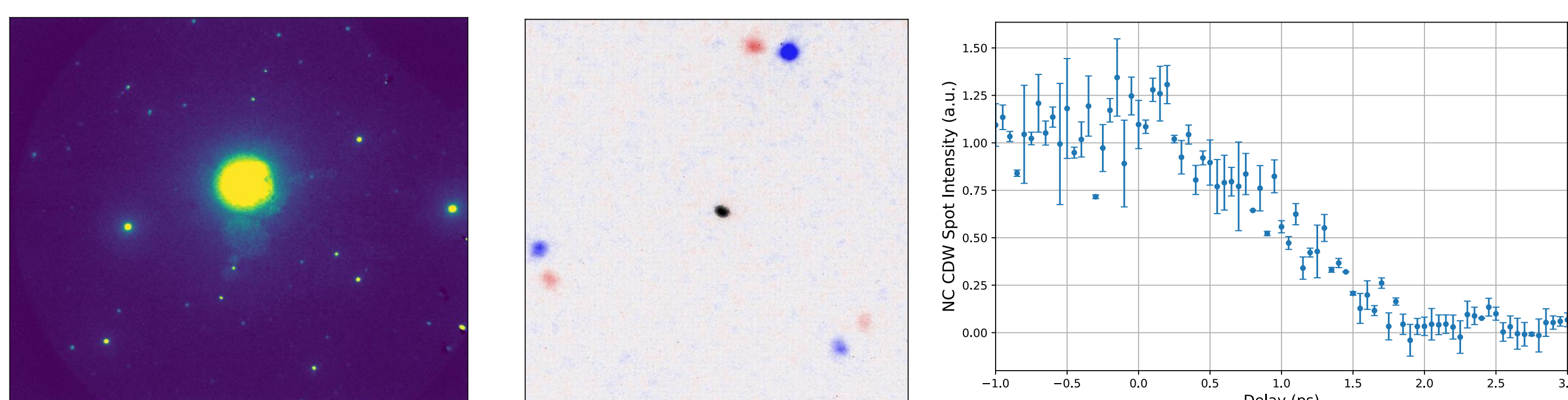
- 1T-polytype tantalum disulfide (1T-TaS₂) is a quasi-two-dimensional van der Waals material with multiple charge density wave (CDW) phases [4]
- Heating due to the laser pump pulse induces a CDW phase change which is detectable by a change in the diffraction image



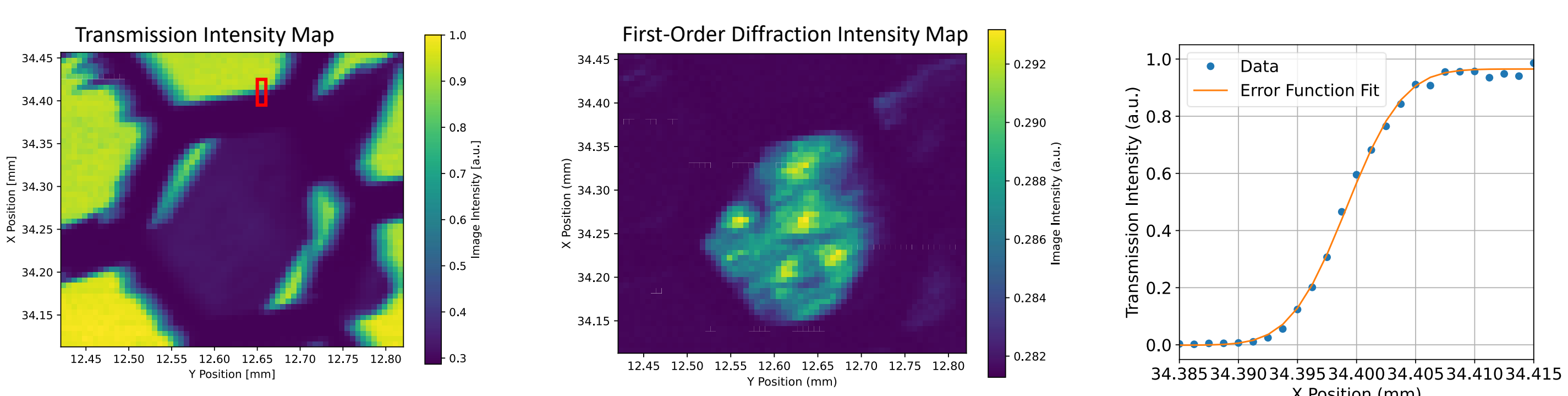
Superstructure caused by the periodic distortion of Ta atoms in 1T-TaS₂



Optical microscope image of an approximately 40nm thick 1T-TaS₂ flake on a 100-mesh grid, used as a sample for diffraction



Left: Electron diffraction image of 1T-TaS₂. Center: First-order diffraction spot (black), surrounded by CDW spots of the nearly commensurate (NC, red) and commensurate (IC, blue) phase after laser excitation. Right: Intensity of a NC CDW spot in relation to the delay t



Raster Scan of a 1T-TaS₂ flake with the intensity given by the transmission spot (left) and by a first-order diffraction spot (center). The intensity profile across the line marked in the transmission image is shown on the right. From an error function fit a spatial resolution of $12.5(4)\mu\text{m}$ (FWHM) is calculated

Discussion

- Due to the drastic intensity change, the transient electric field effect is well suited as a straightforward and easy method for determining the spatial and temporal overlap in pump-probe experiments using electron probe and optical pump pulses
- The possibility of using high laser fluences up to the damage threshold (and beyond) and the fast recovery allow for high repetition rates and thus fast data acquisition
- It is an accessible method for electron pulse duration measurements, but due to the rather slow dynamics of the electron cloud, only an upper limit on electron pulse duration may be derived
- Faster processes are needed for a more precise determination of the pulse duration, e.g., CDW phase change in 1T-TaS₂ [5]

References and Acknowledgments

- [1] D.S. Badali et al., Struct. Dyn. **3**, 034302 (2016)
- [2] H. Park and J.M Zuo, Appl. Phys. Lett. **94**, 251103 (2009)
- [3] Max Gulde et al., Science **345** (6193), 200-204 (2014)
- [4] A.A. Balandin et al., Appl. Phys. Lett. **119**, 170401 (2021)
- [5] C. Lauthé et al., Phys. Rev. Lett. **118**, 247401 (2017)



European Research Council
Established by the European Commission